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## Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713618290

Editorial board page for "Phosphorus, Sulfur, and Silicon and the Related Elements", Volume 123, Number 1

**To cite this Article** (1997) 'Editorial board page for "Phosphorus, Sulfur, and Silicon and the Related Elements", Volume 123, Number 1', Phosphorus, Sulfur, and Silicon and the Related Elements, 123: 1, a

To link to this Article: DOI: 10.1080/10426509708044192 URL: http://dx.doi.org/10.1080/10426509708044192

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# Phosphorus, Sulfur, and Silicon and the Related Elements

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Original articles, communications, and selected reviews of broad interest will be considered for publication. Manuscripts may include illustrative material in color if this will enhance the presentation. There are no page charges and 25 free reprints will be supplied to the principal author. Regular papers may be sent to R. R. Holmes in Amherst or to L. Maier in Basel. Communications and reviews should be sent to W. Walter in Hamburg or J. G. Verkade in Ames.

Notes for contributors, including information on communications and reviews, can be found at the back of the journal.

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